



2021

Call for Papers

20th International Workshop on Junction Technology (IWJT2021)

June 10th on Thursday – 11th on Friday, 2021,

Through On-line



<http://www.iwailab.ep.titech.ac.jp/IWJT/>

The **20th** International Workshop on Junction Technology (IWJT**2021**) will be held on **June 10th on Thu. – 11th on Fri., 2021 through on-line**. The IWJT, started in 2000 and was held annually in Japan or China, is an open forum focused on the needs and interests of the community on a junction formation technology in semiconductors. At the past IWJTs, a number of eminent and experienced scientists and engineers from Asia, America and Europe presented their latest results on junction technology. The workshop will provide a good opportunity for researchers and engineers to present their new research results, and exchange ideas with leading scientists.

Scopes of Workshop

Papers are solicited in, but not limited to the following

- ***Doping Technology***
- ***Annealing Technology***
- ***Junction Technology for Devices***
(CMOS devices, Power devices, Image sensors, Solar cells, etc.)
- ***Silicide and Contact Technology***
- ***Characterization for Junction***
- ***Modeling and Simulation***
- ***Advanced Equipment, Materials and Substrates***
for Junction Technologies

Japanese side committee

General Chair : Hitoshi Wakabayashi (Tokyo Institute of Technology)

Executive Chair : Jiro Matsuo (Kyoto University)

Program Chair : Satoshi Shibata (Panasonic)

Deadline of Camera-ready full manuscript (2-4 pages) submission: ~~April 16, 2021~~

May 6, 2021 (Extended)

For detailed information, please visit the following URL;

<http://www.iwailab.ep.titech.ac.jp/IWJT/>

or contact to Secretariat: iwjt@iwailab.ep.titech.ac.jp

We will prepare two types of awards in this conference.

The Best paper award will be selected from all regular papers.

The Young award will be selected from all the authors of regular papers under 35 age as of **21/06/10**.